

ABSTRACT OF THE DISCLOSURE

TITLE OF INVENTION: LIQUID APPLICATION METHOD AND METHOD OF
MANUFACTURING ELECTRONIC DEVICES USING THE
SAME LIQUID APPLICATION METHOD

The present invention aims to form a thin coating film of even thickness within a short processing time under a curtailed consumption of coating liquid; where, a gas is spouted from nozzle 4 disposed facing to protection glass 2 of cathode ray tube, and a liquid containing fluorescent material is made to spout accompanied by the spouting gas, to be applied on protection glass 2 by shifting the positioning of protection glass 2 relative to nozzle 4 while spouting the liquid containing fluorescent material.